



Attorney Docket No. 5470-316

1456
7/11/03
#71Am16
A
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: DeSimone et al.
Serial No.: 09/975,211
Filed: October 10, 2001

Group Art Unit: 1756
Examiner: Nicole M. Barreca
Confirmation No.: 7807

For: CO₂ PROCESSES PHOTORESISTS, POLYMERS, AND PHOTOACTIVE
COMPOUNDS FOR MICROLITHOGRAPHY

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July 1, 2003

Mail Stop Non-Fee Amendment
Commissioner for Patents
Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

This Amendment is responsive to the Restriction Requirement of June 2, 2003. Applicant is filing the present Amendment pursuant to the Revised Amendment Format instituted by the prototype Electronic File Wrapper program described in 1265 Off. Gaz. Pat. Office 87 (December 17, 2002) and that has been expanded to include all Technology Centers and amendments to the specification and drawings. Thus, the provisions of 37 C.F.R. 1.121(a), (b), (c) and (d) are waived for the present Amendment..